AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

Claims 18-52 (Canceled)

Claim 1 (Original) An image recording medium comprising a support permeable to a reading electromagnetic wave and a first electrode layer permeable to the reading electromagnetic wave, a reading photoconductive layer which exhibits conductivity upon exposure to the reading electromagnetic wave, a charge accumulating portion which accumulates an electric charge of a latent image polarity generated in a recording photoconductive layer, the recording photoconductive layer which exhibits conductivity upon exposure to a recording electromagnetic wave and a second electrode layer permeable to the recording electromagnetic wave which are superposed on the support one on another in this order,

wherein at least one of the recording photoconductive layer and the reading photoconductive layer is formed of a material containing a-Se as a major component and doped with a material for suppressing bulk crystallization of a-Se.

Claim 2 (Original) An image recording medium as defined in Claim 1 in which said material for suppressing bulk crystallization of a-Se is As.

Claim 3 (Original) An image recording medium as defined in Claim 2 in which said at least one of the recording photoconductive layer and the reading photoconductive layer is doped with As in an amount of 0.1 to 0.5atom%.

Claim 4 (Original) An image recording medium as defined in Claim 2 in which said at least one of the recording photoconductive layer and the reading photoconductive layer is doped with Cl in addition to As.

Claim 5 (Original) An image recording medium as defined in Claim 4 in which said at least one of the recording photoconductive layer and the reading photoconductive layer is doped with Cl in amount of 10 to 50ppm.

Claim 6 (Original) An image recording medium as defined in Claim 1 in which the recording photoconductive layer is 400 to 1000μm in thickness.

Claim 7 (Original) An image recording medium as defined in Claim 6 in which the recording photoconductive layer is 700 to 1000μm in thickness.

Claim 8 (Original) An image recording medium comprising a support permeable to a reading electromagnetic wave and a first electrode layer permeable to the reading electromagnetic wave, a reading photoconductive layer which exhibits conductivity upon exposure to the reading electromagnetic wave, a charge transfer layer which behaves like a substantially insulating material to an electric charge of a latent image polarity generated in a recording photoconductive layer and behaves like a substantially conductive material to the electric charge of the polarity opposite to the latent image polarity, the recording photoconductive layer which exhibits conductivity upon exposure to a recording electromagnetic wave and a second electrode layer permeable to the recording electromagneticwave which are superposed on the support one on another in this order,

wherein the charge transfer layer is formed of a material containing a-Se as a major component and doped with a material for suppressing bulk crystallization of a-Se.

Claim 9 (Original) An image recording medium as defined in Claim 8 in which the charge transfer layer is doped with As in an amount of 0.1 to 0.5atom% and with Cl in amount of 10 to 50ppm.

Claim 10 (Original) An image recording medium as defined in Claim 8 in which the recording photoconductive layer is 400 to 1000μm in thickness.

Claim 11 (Original) An image recording medium as defined in Claim 10 in which the recording photoconductive layer is 700 to 1000μm in thickness.

Claim 12 (Original) A method of manufacturing an image recording medium comprising a support permeable to a reading electromagnetic wave and a first electrode layer permeable to the reading electromagnetic wave, a reading photoconductive layer which exhibits conductivity upon exposure to the reading electromagnetic wave, a charge accumulating portion which accumulates an electric charge of a latent image polarity generated in a recording photoconductive layer, the recording photoconductive layer which exhibits conductivity upon exposure to a recording electromagnetic wave and a second electrode layer permeable to the recording electromagnetic wave which are superposed on the support one on another in this order, the method characterized in that the recording photoconductive layer is formed in a thickness of 200 to 1000μm by resistance heating deposition of an alloy material containing therein Se as a major component and doped with 0.1 to 0.5atom% of As and 10 to 50ppm of Cl.

Claim 13 (Original) A method as def fined in Claim 12 in which the recording photoconductive layer is formed in a thickness of 400 to 1000 im.

Claim 14 (Original) A method as def fined in Claim 13 in which the recording photoconductive layer is formed in a thickness of 700 to 1000μm.

Claim 15 (Original) A method of manufacturing an image recording medium comprising a support permeable to a reading electromagnetic wave and a first electrode layer permeable to the reading electromagnetic wave, a reading photoconductive layer which exhibits conductivity upon exposure to the reading electromagnetic wave, a charge transfer layer which behaves like a substantially insulating material to an electric charge of a latent image polarity generated in a recording photoconductive layer and behaves like a substantially conductive material to the electric charge of the polarity opposite to the latent image polarity, the recording photoconductive layer which exhibits conductivity upon exposure to a recording electromagnetic wave and a second electrode layerpermeabletotherecordingelectromagneticwave which are superposed on the support one on another in this order, the method characterized in that the recording photoconductive layer is formed in a thickness of 200 to 1000μm by resistance heating deposition of an alloy material containing therein Se as a major component and doped with 0.1 to 0.5atom% of As and 10 to 50ppm of Cl.

Claim 16 (Original) A method as defined in Claim 15 in which the recording photoconductive layer is formed in a thickness of 400 to 1000μm.

Claim 17 (Original) A method as def ined in Claim 16 in which the recording photoconductive layer is formed in a thickness of 700 to 1000μm.